

**Search Notes**

Application No.

10/657,451

Examiner

John Juba, Jr.

Applicant(s)

PARKER ET AL.

Art Unit

2872

**SEARCHED**

Class	Subclass	Date	Examiner
359	20	8/6/2004	JJ
Updated	Above	10/4/2005	JJ
359	19	10/4/2005	JJ
UPDATED from Parent as follows: 08/972,464			
359	12	10/4/2005	JJ
359	15	10/4/2005	JJ
359	32	10/4/2005	JJ
359	33	10/4/2005	JJ
359	900	10/4/2005	JJ
430	5	10/4/2005	JJ

**INTERFERENCE SEARCHED**

Class	Subclass	Date	Examiner

**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
Parent filewrapper 08/972,464 in LOC 7581 for cert. of correction	8/6/2004	JJ
Masks for forming the ILHM can be Type I (non-opaque) or Type II (opaque).	8/6/2004	JJ
Non-opaque may include semi-transparent film (0.1 - 5 O.D.) film with substantially transparent element regions therein.	8/6/2004	JJ
Reviewed parent filewrapper.	10/4/2005	JJ